

Ion Chemistry in Cold Plasmas of H₂ with CH₄ and N₂

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The distributions of ions and neutrals in low-pressure ($\approx 10^{-2}$ mbar) DC discharges of pure hydrogen and hydrogen with small admixtures (5%) of CH₄ and N₂ have been determined by mass spectrometry. Besides the mentioned plasma precursors, appreciable amounts of NH₃ and C₂H_x hydrocarbons, probably mostly from wall reactions, are detected in the gas phase. Primary ions, formed by electron impact in the glow region, undergo a series of charge transfer and reactive collisions that determine the ultimate ion distribution in the various plasmas. A comparison of the ion mass spectra for the different mixtures, taking into account the mass spectra of neutrals, provides interesting information on the key reactions among ions. The prevalent ion is H₃⁺ in all cases, and the ion chemistry is dominated by protonation reactions of this ion and some of its derivatives. Besides the purely hydrogenic ions, N₂H⁺, NH₄⁺, and CH₅⁺ are found in significant amounts. The only mixed C/N ion clearly identified is protonated acetonitrile C₂H₄N⁺. The results suggest that very little HCN is formed in the plasmas under study.

1. Introduction

Hydrogen is the dominant molecular species in interstellar space, and consequently, the ions H⁺, H₂⁺, and H₃⁺ derived from this molecule play a key role in its gas-phase chemistry which, under the very low temperatures and densities typical of this medium, is essentially driven by ion–molecule reactions. In particular, the H₃⁺ ion, relatively stable in interstellar space,^{1,2} constitutes an excellent protonating agent³ given the very low proton affinity of H₂ and high cross sections typical of ion–molecule encounters. It is generally assumed that H₃⁺ forms the basis for an extensive network of ion–molecule processes involving initially light species containing mostly C, O, and N that are responsible for creation of many of the molecules observed in interstellar space (see refs 4–6 and references therein). In fact, only 13 ions have been positively identified in the interstellar medium,⁶ but many others are postulated in current astrochemistry models.^{4,5} Likewise, models of the ionospheres of the giant planets indicate that they are largely dominated by H⁺ and H₃⁺ in their upper layers. Other ions, mostly derived from reactions of H_x⁺ with methane, begin to appear with decreasing altitude.⁷

Ion–molecule reactions of H_x⁺ species and hydrocarbons are also important in other media of technological interest like those used in plasma-enhanced chemical vapor deposition (PECVD) of diamond-like and amorphous hydrogenated carbon (a-C:H) films.^{8–11} In these cold plasmas, hydrogenic ions contribute to formation of C_xH_y⁺ species, which can play an important role in film formation. Although in many cases carbonaceous radicals are deemed the main film precursors, ion bombardment can help decisively to film growth through creation of dangling bonds and other reactive sites.^{12–14} Depending on the circumstances,

ions can also contribute directly to film growth.^{15,16} Both positive and negative carbonated ions are assumed to play a significant role in hydrocarbon nanoparticle nucleation.¹⁷

Molecular nitrogen or nitrogen-containing species were introduced in hydrocarbon plasmas in an attempt to synthesize crystalline β -C₃N₄, a material with predicted properties superior to those of diamond.¹⁸ In spite of intense research efforts, no unambiguous experimental evidence of the production of this crystalline material was reported.¹⁹ These investigations showed that incorporation of nitrogen to the growing carbon films is difficult; furthermore, the presence of nitrogen-containing species was found to hamper or preclude completely the deposition of hydrogenated carbon or carbon nitride compounds for a broad range of experimental conditions.²⁰ Inhibition of a-C:H film formation in the presence of nitrogenous species has been shown to be of interest for development of nuclear fusion reactors. Carbon-based materials exhibit the best general behavior against high thermal loads and other extreme conditions and are used in divertors and limiters in these devices.²¹ Unfortunately, the high reactivity of carbon with hydrogenic isotopes, especially at high temperatures, leads to strong chemical sputtering which shortens the material lifetime and contributes to formation of a-C:H films, rich in deuterium and tritium proceeding from the fusion fuel. These deposits are formed in parts of the device not directly exposed to the hot plasma, especially in cold plasma regions after the divertor. In this way, radioactive tritium retention has become a major issue for the normal operation of next-step fusion reactors.^{21,22} Encouraging results with moderate reductions of carbon redeposition induced by injection of nitrogen have already been obtained in actual fusion devices.^{20,23} At present, the detailed mechanisms by which N-containing compounds hamper film growth are under debate. Various gas-phase and surface processes involving neutrals and ions are currently being considered.^{24–30}

In spite of the evident relevance of all the plasmas mentioned in the previous paragraphs, the ionic composition and underlying

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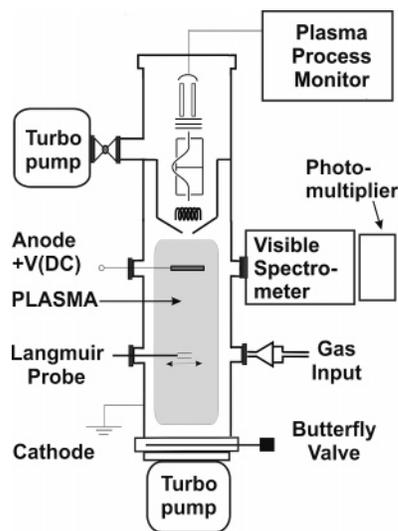


Figure 1. Schematic illustration of the experimental setup.

chemistry of hydrogen-dominated cold plasmas are often poorly known. Even pure hydrogen plasmas, apparently simple from a chemical point of view, may require consideration of a high number of processes due to the multiple interactions of neutral and charged particles and the various degrees of internal excitation of atoms and molecules (see refs 31–36 and references therein). A proper understanding of the ion chemistry of cold H_2 plasmas will be best achieved through a combination of detailed experimental diagnostics and kinetic analysis. Two examples of this approach have been recently reported.^{37,38} Hollmann and Pigarov³⁷ measured ion concentrations in a hydrogen reflex arc discharge characterized by high electron and ion densities (10^{11} – 10^{12} cm^{-3}). The results of these measurements were successfully modeled by the authors using a reduced set of rate equations and cross-section data from the literature. In a recent study³⁸ we investigated the plasmas produced in a low-pressure H_2 DC hollow cathode (HC) discharge. Although they differ from the reflex-arc discharges, most notably in their electron density (which is of the order of 10^{10} cm^{-3} in the HC plasmas), a kinetic model using the same basic reactions considered by Hollmann and Pigarov³⁷ could account for the experimental observations. In our plasmas, H_2 was found to have a high vibrational excitation, and H_3^+ was the dominant ion when the ionic mean free path approached the dimensions of the glow. In the present work, we extend the previous investigation to more complex mixtures relevant for the plasmas mentioned in the previous paragraphs. In an attempt to identify key species and processes in the chemistry of hydrogenic ions with small hydrocarbons and nitrogen, we measured the mass spectra of the ions and neutrals present in HC discharges of pure H_2 and mixtures of H_2 with small amounts of either CH_4 or N_2 or with both compounds together. The results are analyzed and discussed in light of available kinetic data. Mass spectra of the neutral species in these plasmas were studied previously in a more detailed way by our group.^{27,29,39}

2. Experimental Section

The experimental plasma reactor, shown in Figure 1, is basically the same as in our previous works on air and hydrogen plasmas.^{38,40,41} It consists of a grounded cylindrical stainless steel vessel (10 cm diameter, 34 cm length) and a central anode. The vessel walls are provided with a number of ports for

connection of gas inlets, diagnostics tools, observation windows, and pressure gauges (not all shown in Figure 1).

The reactor was continuously pumped by a 450 L/s turbomolecular pump in series with a rotary pump to a base pressure of 10^{-6} mbar. The desired reactor pressure and gas mixture composition were selected by balancing the input gas flow for each gas with a needle valve in the gas inlet. A total gas pressure of $P = 0.02$ mbar $H_2/N_2(0-5\%)/CH_4(0-5\%)$, measured with a capacitance absolute manometer, was used. The stability of the composition in the various mixtures was additionally checked by measuring the peaks in the mass spectra of H_2 , CH_4 , and N_2 (see below). Residence times, τ_{res} , of the various plasma precursors were determined by cutting suddenly with a quick connector the flow of each component to the reactor and monitoring its decay time by time-resolved mass spectrometry. Residence times of ~ 0.1 s were measured for CH_4 and N_2 , and a value of ~ 0.4 s was obtained for H_2 . The differences are due to the distinct pumping speed of the turbomolecular pump for the diverse species. Plasma currents $I_p \approx 150$ mA and supply voltages $V \approx 400$ V were used in the discharges of pure H_2 or $H_2(5\%) N_2$. In the mixtures containing (5%) CH_4 the discharge current was seen to drop by about 20% and the voltage rose in the same proportion. In order to initiate the discharges at this low operation pressure, an electron gun built in our laboratory, consisting basically of a tungsten filament operating at 2 A and -2000 V_{DC}, was employed.

A Plasma Process Monitor, Balzers PPM421, was used for detection of both neutrals and ions from the plasma. It consists of an electron bombardment ionizer, an electrostatic focusing system, a cylindrical mirror energy analyzer, and a quadrupole mass filter with a secondary electron multiplier in the counting mode. The background signal from the PPM chamber was subtracted in the measurements of neutrals. For detection of ions, the electron bombardment ionizer is switched off and the ions are allowed to enter the detector directly from the plasma. The apparatus was installed in a differentially pumped chamber connected to the reactor through a $100 \mu m$ diaphragm. During operation the pressure in the detection chamber was kept in the 10^{-7} mbar range by means of a turbomolecular pump and a dry pump.

Ion fluxes were calculated by integrating the ion energy distributions recorded in the experiments for each individual mass value. These energy distributions were essentially concentrated in a large and sharp maximum (fwhm ≈ 2 V) at energies very close to that of the discharge potential. Some of them also had a broad and weak tail extending to lower potentials. The relative sensitivity of the plasma monitor (including electrical filters and electron multiplier) to the different ion masses was checked by filling the chamber of the PPM421 with a small pressure of H_2 , He, Ne, Ar, and Xe and comparing in each case the PPM signal, weighted by the respective ionization cross section at the chosen electron energy (70 eV), with the chamber pressure as determined from the reading of a Bayard–Alpert gauge with the appropriate correction factor. As shown by Pecher,⁴² this calibration procedure is also adequate for ions extracted from the plasma. The calibration led to a sensitivity dependence roughly proportional to $m^{-0.5}$, in agreement with other authors.^{42,43}

The radial distribution of electron mean temperature and total charge density in the cylindrical reactor were measured with a double Langmuir probe built in our laboratory⁴⁴ by assuming a collision-free probe sheath and orbital limited motion.⁴⁵ It is also tacitly assumed that negative ions are negligible in the

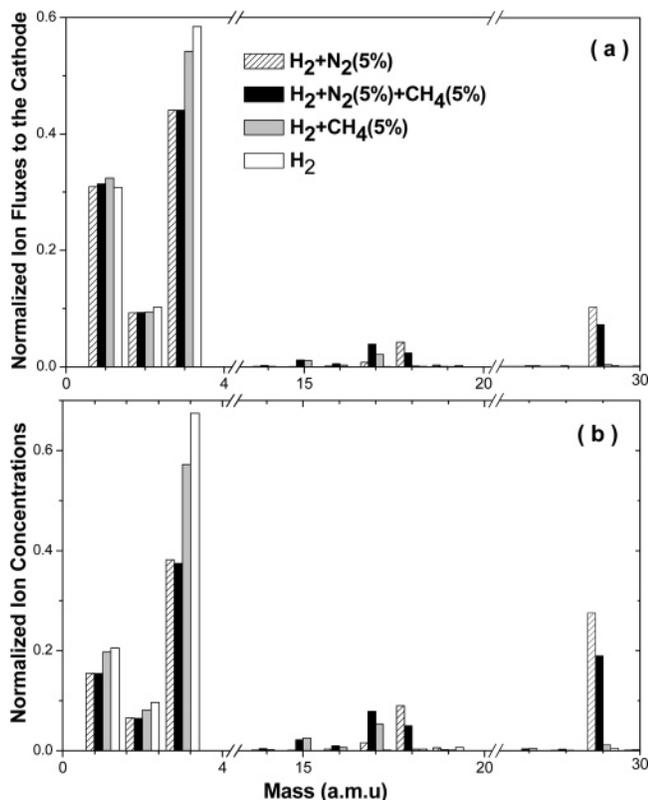


Figure 4. (a) Flux distributions of the ions reaching the cathode normalized to one for the four discharges investigated: pure H_2 , and H_2 mixed with 5% N_2 , 5% CH_4 , and 5% $\text{N}_2 + 5\% \text{CH}_4$. (b) Normalized to one concentrations of ions in the plasma corresponding to the discharges of the upper panel (4a) (see text). For identification of the different ions, see text and Figure 5.

Hydrogenic ions, in particular ions with $m/q = 3$ (H_3^+), were found to be preponderant in all cases, in accordance with the expectations for the conditions of this type of plasmas whose composition is essentially dominated by molecular hydrogen.^{37,38,48} In plasmas containing CH_4 or N_2 appreciable contributions from masses higher than three can be observed. Note, in particular, the change in the ion flux distribution in nitrogen-containing plasmas, where a peak at $m/q = 29$ accounts for 8–10% of the ion flux and where the contribution of H_3^+ ions is reduced by about 20% with respect to that of pure hydrogen plasmas. Ion peaks between 1% and 5% are observed at masses 15, 17, and 18.

Instead of ion fluxes, Figure 4b shows the estimated distributions of ion concentrations (volume densities) in the plasma for the various discharges considered. The flow of ions from the plasma to the cathode is regulated by their Bohm velocity,⁴⁶ which is inversely proportional to the square root of the ion mass. Consequently, in order to derive the ion concentrations in the plasma, the ion flux signals corresponding to a given mass, m_i , were multiplied by $m_i^{0.5}$. Note that due to their comparatively small flow velocity, heavier ions tend to concentrate in the plasma. In particular, in the N_2 -containing plasmas the ions of mass 29 contribute largely to the total ion concentration. We will focus the following discussion on concentrations rather than on cathode fluxes, since they are more meaningful for the ion chemistry within the plasma.

A large number of ions contributing less than 1% to the total ion concentration can be also observed in a logarithmic scale in Figure 5, where all significant signals in the $m/q = 0$ –45 range have been represented. Some weaker peaks were also found at higher masses, but their contribution to the global ion

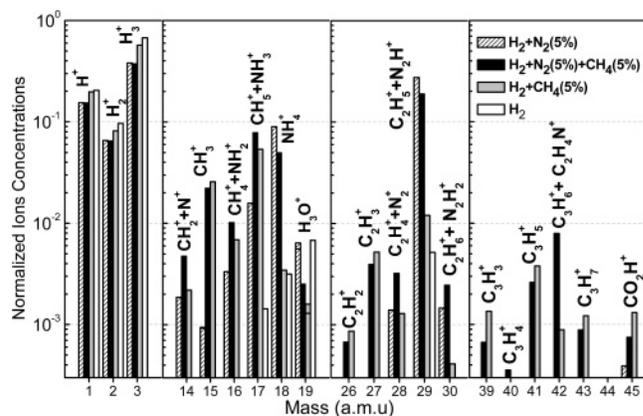


Figure 5. Normalized ion concentrations in semilogarithmic scale extended up to 46 amu in the same conditions of Figure 4. The ions corresponding to the various m/q values are identified in the figure. When more than one ion can contribute to a given m/q value, the preponderant species is written first (see text).

density is negligible and will not be considered. Leaving aside pure hydrogenic ions, $m/q = 18$ (NH_4^+) and 29 (N_2H^+) were found to be prevalent in the $\text{H}_2 + (5\%)\text{N}_2$ plasmas; whereas in the $\text{H}_2 + (5\%)\text{CH}_4$ discharges $m/q = 15$ (CH_3^+) and $m/e = 17$ (CH_5^+) were seen to dominate. The same ions are found to be dominant in other types of methane discharges,^{49,50} and a similar decrease in H_3^+ , accompanied by a growth in CH_5^+ upon addition of a small amount of CH_4 to a capacitively coupled H_2 discharge, has been recently reported.⁵⁰ Smaller ion peaks with intensities below 0.5% appeared mostly grouped in clusters of $m/q = 14$ –19, 26–30, and 39–45. The first two of these clusters correspond to C_xH_y^+ ions with $x = 1$ and 2. The third cluster is due mostly to C_3H_y^+ ions. The peaks of hydrocarbon ions, C_xH_y^+ , decrease in intensity with growing carbon number, as expected for typical low-pressure cold plasmas containing methane.^{42,51} With increasing methane pressure, the number of ions with more carbon atoms grows significantly.^{8,42} Identification of ion peaks in $\text{H}_2 + \text{N}_2 + \text{CH}_4$ gas mixtures is more difficult than in the two binary mixtures, since some of the ion peaks could have contributions from N_xH_y^+ , C_xH_y^+ , and even $\text{C}_x\text{N}_y\text{H}_z^+$ species.^{51,52} By comparing the peak measured for a given m/q value in the various gas mixtures, some of the signals could be assigned unambiguously to carbon or nitrogen ions. This was the case of $m/q = 15$ (CH_3^+), 26 (C_2H_2^+), and 27 (C_2H_3^+), which were absent, or more than 1 order of magnitude weaker, when CH_4 was not added to the precursor gas. Among them, CH_3^+ was always the major one. The same behavior was observed for heavier ions like 39 (C_3H_3^+), 41 (C_3H_5^+), and 43–45 (C_3H_7^+). For the same reason, the prominent peaks at $m/q = 18$ and 29 must be due to the nitrogenic ions NH_4^+ and N_2H^+ . Some other masses in the ion spectra of the ternary mixture could not be assigned to a single ion but to the additive contribution of N_xH_y^+ and C_xH_y^+ species, since they have significant intensities in the three mixtures. This was the situation for $m = 14$ ($\text{N}^+ + \text{CH}_2^+$), 16 ($\text{CH}_4^+ + \text{NH}_2^+$), 17 ($\text{CH}_5^+ + \text{NH}_3^+$), 28 ($\text{N}_2^+ + \text{C}_2\text{H}_4^+$), 29 ($\text{N}_2\text{H}^+ + \text{C}_2\text{H}_5^+$), and 30 ($\text{N}_2\text{H}_2^+ + \text{C}_2\text{H}_6^+$). Among them, the largest contribution to carbon ions was undoubtedly that of mass 17 (mainly CH_5^+), which exceeded the concentration of CH_3^+ in all cases. Comparison of the signal intensities corresponding to $m/q = 28$, 29, and 39 in the different mixtures suggests a negligible contribution of C_xNH_z^+ mixed C–N ions. Nevertheless, a single hybrid C–N ion was clearly identified at $m = 42$ ($\text{C}_2\text{H}_4\text{N}^+$); this peak was only significant in the $\text{H}_2/\text{N}_2(5\%)/\text{CH}_4(5\%)$

mixture and decreased by at least 1 order of magnitude when either N₂ or CH₄ were removed from the feed gas.

4. Discussion

Gas-Phase Neutrals and Wall Processes. Before starting the discussion on ion chemistry, which is the main objective of the present work, we will make some general comments on the neutral species observed in our discharges and on their likely origin.

Under our experimental conditions, with a discharge power of ~50 W, a discharge volume of ~3l, and residence times of the molecules in the reactor $\tau_{\text{res}} \approx 0.1$ s for N₂ and CH₄ and $\tau_{\text{res}} \approx 0.4$ s for H₂, a low dissociation degree (~5% for N₂ and ~15% for CH₄ and H₂) was obtained in the plasmas under study; as a consequence, the gas composition is dominated by the plasma precursors (H₂, CH₄, and N₂) and only small amounts of other compounds (NH₃, C_xH_y) are found in the mass spectra, as shown in Figure 3. The concentrations of NH₃ and C₂H_x molecules are about 1 order of magnitude lower than those of N₂ and CH₄.

Different mechanisms including gas-phase and surface reactions could be, in principle, responsible for formation of the minor neutral species, but the present data do not allow a determination of the actual production mechanisms. Gas-phase generation of C_xH_y hydrocarbons and NH₃ molecules would require bimolecular reactions between molecules and radicals with typical rate constants in the 10⁻¹⁰–10⁻¹¹ cm³ s⁻¹ range.^{17,53} The contribution of this channel depends on the concentrations of radicals, which could not be determined in the present experiments. Gordiets et al.^{53–55} constructed a detailed kinetic model for low-pressure H₂/N₂ plasmas, including both gas-phase and surface processes, and concluded that surface reactions of physisorbed H and N atoms and NH_x species are needed to account for the observed NH₃ formation in a variety of experiments. Although their results cannot be directly extrapolated to the present case, they stress the likelihood of heterogeneous processes for formation of ammonia in similar plasmas. Efficient NH₃ formation at metallic walls has also been reported in experiments with expanding arch-jet plasmas.⁵⁶ Gas-phase formation of NH₃ is not favored at the low pressures of our experiments, since it requires successive or three body collisions.⁵³ In plasmas with methane, C-containing radicals can also lead through successive collisions to formation of C_xH_y species,^{17,57} but again this mechanism is not favored at low pressure, especially for the heavier C_xH_y molecules. In these plasmas carbonaceous films are deposited at the walls. Interactions of these films with reactive plasma species can also lead to the release of C_xH_y neutral molecules.^{8,42} The situation is even more complex for plasmas with CH₄ and N₂, where nitrogen-containing compounds can interfere in different ways with formation and growth of the carbonaceous films, eventually giving rise to production of volatile compounds containing C or N atoms or both. The detailed comprehension of all these issues, which are nowadays the subject of intense research (see refs 22–29, 30, and 39 and references therein) is beyond the scope of this study, which is rather centered on the ion chemistry of small amounts of carbonaceous and nitrous molecules in low-pressure plasmas dominated by hydrogen.

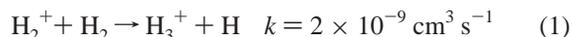
Ion Chemistry. Primary ions in the plasmas are produced by electron impact ionization of the neutral precursors. These ions can then undergo charge transfer or reaction processes through collisions with neutral molecules before reaching the plasma sheath, where they are accelerated toward the cathode. Ion–molecule reactions of the species of interest have very large

rate constants^{58–60} and are relevant, even under the low collision conditions typical of the present experiments ($P \approx 0.02$ mbar, $T_g \approx 300$ K, reactor radius = 5 cm). In addition, the cathode wall acts as an effective cation sink, preventing release of positively charged species from its surface, which implies that the measured distributions of ion concentrations are entirely a consequence of electronic and ionic collisions within the plasma. Moreover, these distributions are largely due to ion–molecule reactions, whose rate constants, mostly in the 10⁻⁹ cm³ s⁻¹ range,^{58,59} compete favorably with those of electron impact ionization, which for the electronic temperatures of our discharges (~4 eV) are in the ~10⁻¹⁰ cm³ s⁻¹ range.^{38,41,60–62} It is useful to recall at this point the hierarchy of concentrations of the various chemical species in the plasmas. Hydrogen molecules have a density of $\sim 5 \times 10^{14}$ cm⁻³, and the concentrations of N₂ and CH₄ are 20 times lower ($\sim 2.5 \times 10^{13}$ cm⁻³). C₂H_x and NH₃ have densities of $\sim 1–2 \times 10^{12}$ cm⁻³. The concentrations of charged particles are much lower; the total electron density is $\sim 10^{10}$ cm⁻³, and those of the individual positive ions range from $\sim 7 \times 10^9$ to 10^7 cm⁻³. Characteristic times, τ , for the reaction of ions with neutrals ($\tau = 1/k \cdot [X]$, where k is the reaction coefficient and $[X]$ the neutral's concentration) will thus be in the tens of microseconds, of the same order than the time needed by ions to reach the cathode^{38,41} and much shorter than the residence time of neutrals in the reactor (0.1–0.4 s). Electron impact neutralization plays a minor role in the depletion of plasma ions in our glow discharges. With typical rate coefficients in the 10⁻⁸ cm³ s⁻¹ range at the relevant electronic temperatures,^{37,63,64} the characteristic times for electron impact neutralization are in the millisecond range, and thus much slower than most ion–molecule reactions. As indicated above, the chemistry of neutrals, with gas-phase bimolecular rate coefficients much smaller than those of ion–molecule reactions,^{17,65,66} is probably dominated by surface processes.

In the following we will describe in some detail the likely chemistry of the different groups of ions observed in our experiments. The ion temperatures could not be measured in the present work, but given the experimental conditions, they should not be much higher than that of the neutrals (~300 K). Throughout the discussion the given rate coefficients refer to the room-temperature values from the critical compilations of Anicich.^{58,59} Even if the ion temperatures were somewhat higher, the rate constant values would not be much affected, since rate constants for barrierless reactions of this type show only a weak dependence on temperature.

Ions of Masses 1–3. The processes of formation and interconversion of the three hydrogenic ions in a low-pressure DC plasma of pure H₂ were addressed in detail in ref 38, and only the details pertinent to the present measurements will be commented on here. In all the plasmas considered the dominant ion is H₃⁺ formed in the reaction.

H₃⁺

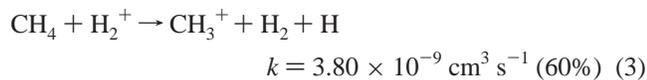
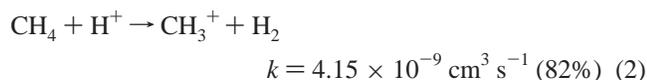


Most of the H₂⁺ ions directly formed by electron impact ionization of the H₂ precursor are transformed to H₃⁺ through reaction 1. H⁺ ions are formed in the electron impact dissociative ionization of H₂ and in the electron impact ionization of H atoms that can reach relatively high concentrations within these plasmas.³⁸ Note that neither H₃⁺ nor H⁺ are lost through reactions with molecular hydrogen, which is the dominant plasma species. However, the three hydrogenic ions can react with other compounds present in the discharge, as we

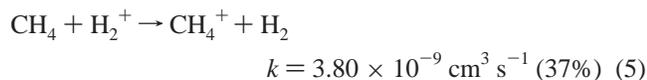
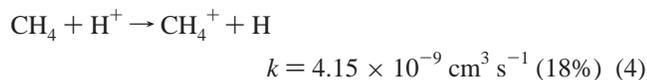
will see below. A pronounced drop in the H_3^+ concentration upon addition of CH_4 to pure H_2 plasmas has been recently reported by Lombardi et al.¹⁰ in a model of a MW discharge for diamond deposition. Figure 4 shows the marked decrease in the relative concentrations of H^+ , H_2^+ , and H_3^+ in our discharges, observed upon addition of a small amount of CH_4 , N_2 , or both. The drop is most pronounced in the case of H_3^+ , especially in plasmas containing N_2 . In diffuse interstellar clouds its main destruction channel seems to be neutralization by electrons.² However, as indicated above, this mechanism is not relevant in our plasmas (see discussion in ref 38) and H_3^+ is lost in reactions with neutrals and in wall collisions at the cathode, where it constitutes the main component of the global ion flux.

Ions of Masses 14–19. The peaks of masses 15, 16, and 17 are much larger in methane-containing plasmas. They correspond to CH_3^+ , CH_4^+ , and CH_5^+ ions that are readily formed in collisions of H^+ , H_2^+ , and H_3^+ with methane. In addition, CH_3^+ and CH_4^+ can be directly produced in the electron impact ionization of CH_4 . The rate constants and branching ratios (in parentheses) for the most relevant ion–molecule reactions are listed here.

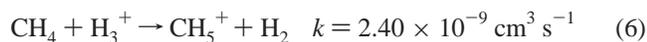
CH_3^+



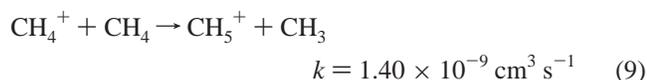
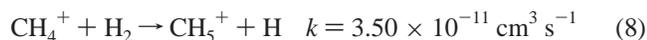
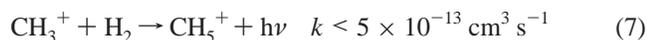
CH_4^+



CH_5^+

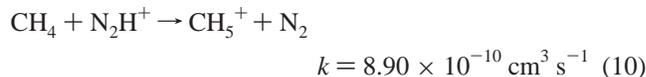


In addition, CH_5^+ can be formed in collisions of CH_3^+ and CH_4^+ with hydrogen and methane



The remarkable structural and reactive properties of the CH_5^+ ion have deserved attention by many research groups (see refs 67–69 and references therein). Although it has not yet been detected in interstellar space,⁶ its presence has been often hypothesized in astrochemistry models. In particular, the radiative association process (eq 7) is thought to play an important role in starless core regions,⁴ where the protonated methane formed can undergo dissociative recombination to produce various hydrocarbon species. However, the rate constant is too small and, in spite of involving collisions with H_2 , which is the most abundant species in the discharges of the present study,

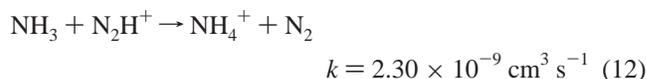
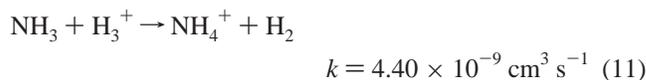
reaction 7 does not contribute appreciably to the destruction of CH_3^+ or formation of CH_5^+ . In contrast, reactions 8 and 9 contribute somewhat to the total production of CH_5^+ and destroy a significant amount of the CH_4^+ ions formed in reactions 4 and 5. The branching ratios of reactions 2 and 4 and 3 and 5 indicate that formation of CH_3^+ is favored as compared with CH_4^+ . This fact and the more efficient destruction pathways for CH_4^+ justify the relative concentrations of CH_3^+ and CH_4^+ observed in the measurements. CH_5^+ , the prevailing carbonated ion in the plasmas studied, is basically generated through reaction 6 in collisions of methane with the most abundant ion, H_3^+ . In mixed plasmas with CH_4 and N_2 there is an additional production channel



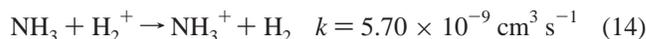
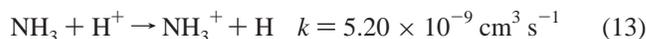
implying collisions of methane with the dyazenilium ion, N_2H^+ , which is the second ion in importance in the nitrogenated discharges considered in this work, as shown in Figure 5 and discussed in the next paragraph. Note that due to reaction 10 the relative concentration of N_2H^+ decreases and that of CH_5^+ increases in the plasmas with H_2 , CH_4 , and N_2 as compared with the respective concentrations in the plasmas containing just H_2 and N_2 or H_2 and CH_4 . All the CH_x^+ ions discussed thus far can react with NH_3 or C_2H_x , molecules which appear as secondary products in the discharges under consideration (see below).

In Figure 5 the largest ion peak in the 15–19 interval is found at $m/e = 18$ for the H_2/N_2 discharge. This peak is due to the ammonium ion NH_4^+ , which is formed mainly through the following reactions

NH_4^+



Other minor channels leading to formation of NH_4^+ involve reactions of NH_3^+ with H_2 and CH_4 and of CH_x^+ with NH_3 .^{58,59} Formation of significant amounts of NH_3 as a result of heterogeneous wall reactions in low-pressure H_2/N_2 plasmas is well documented in the literature (see refs 53–56 and references therein). Under the conditions of our discharges, the concentration of NH_3 amounts roughly to 10% of the concentration of N_2 or methane. The relatively high NH_4^+ density observed, which is of the same order than that of the most intense carbonated ion, CH_5^+ , is thus surprising at first sight; however, the ammonium ion is very stable and, unlike CH_x^+ ions, does not react appreciably with H_2 , N_2 , or the hydrocarbons present in the discharges.^{58,59} The signal at mass 17 in N_2/H_2 plasmas is due to NH_3^+ and formed partly through direct electron ionization and partly in the reactions

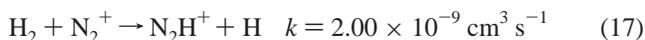
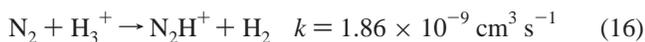
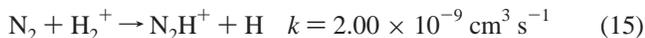


Minor contributions of ions from electron impact ionization of CH_4 , N_2 , and NH_3 are found at masses 14 (CH_2^+ , N^+), 15 (NH^+), and 16 (NH_2^+). At $m/q = 19$, residual water molecules

in the chamber give a weak signal corresponding to protonated water, H₃O⁺, in the four plasmas investigated.

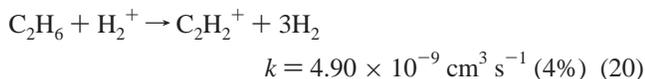
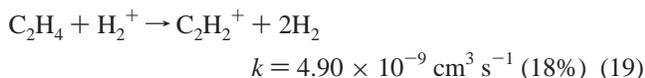
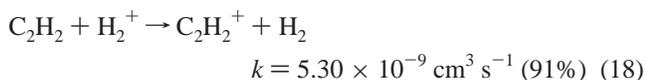
Ions of Masses 26–30. In the N₂-containing discharges a very intense peak appears at $m/q = 29$. This peak, which is the second in intensity of the whole spectrum, corresponds to the dyazenilium ion formed in the reactions.

N₂H⁺

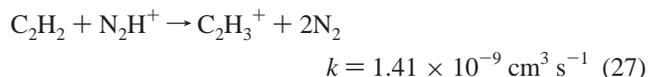
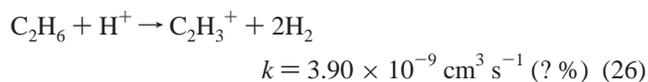
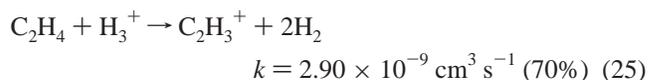
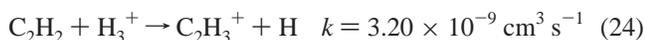
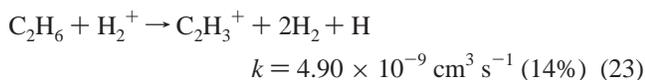
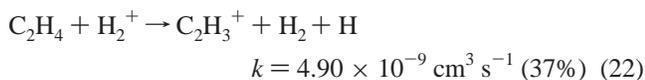
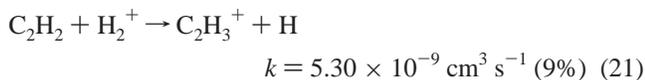


The three formation channels are efficient, in particular reactions 16 and 17 which involve the most abundant plasma ion (H₃⁺) and neutral species (H₂), respectively. Due to its comparatively high mass, the flow of N₂H⁺ to the cathode is slow and its concentration is enriched in the plasma. The dyazenilium ion has been directly observed in interstellar clouds where it is often used in conjunction with collisional radiative models to derive the abundance of molecular nitrogen, which cannot be directly detected with the usual astrophysical spectroscopic techniques (see refs 6 and 70 and references therein). Once formed N₂H⁺ does not react with H₂ or N₂ but reacts with CH₄ (reaction 10) and other hydrocarbons, as shown below. Ions of C₂H_x⁺ are mainly formed by electron impact or in ion–molecule reactions of C₂H_x neutrals (especially C₂H₂ and C₂H₄ in the present case). Consequently, their concentration is in general lower than that of CH_x⁺ species. Hydrogenic ions and N₂H⁺ are again the protonating agents. The main C₂H_x⁺ formation reactions and their respective branching ratios, in parentheses, are listed here.

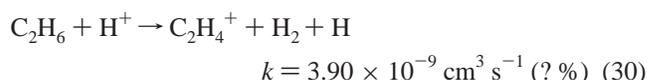
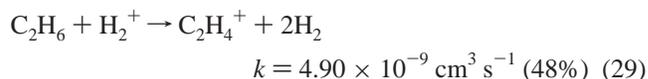
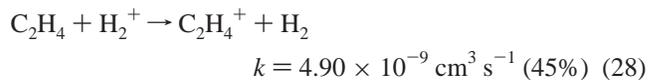
C₂H₂⁺



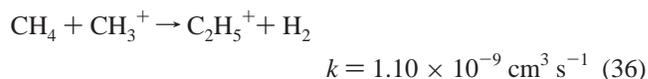
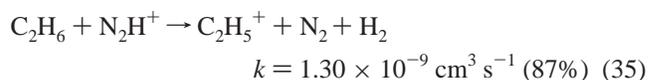
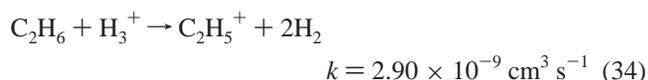
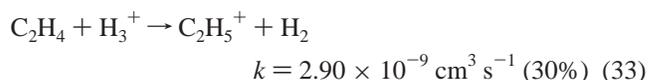
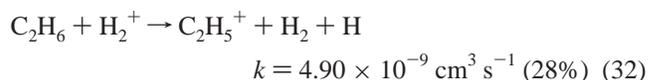
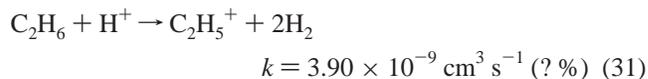
C₂H₃⁺



C₂H₄⁺



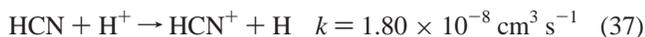
C₂H₅⁺



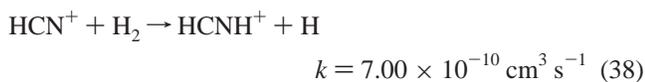
Reaction 36 is particularly interesting, since it describes a process of molecular aggregation giving rise to a higher mass hydrocarbon ion. Collisions of this type have been found to be determinant for the ion distributions in plasmas with higher methane pressures^{8,42} which can be dominated by C_yH_x⁺ ions with y values higher than 1. In the present case, reaction 36 may contribute appreciably to C₂H₅⁺ formation. The branching ratios for the different channels of the C₂H₆ reaction with H⁺, corresponding to processes 26, 30, and 31, are not given in the compilations of Anicich^{58,59} and have been signaled with a question mark. Note that C₂H₂⁺ and C₂H₄⁺ are just formed in reactions with H₂⁺, whereas C₂H₅⁺ and C₂H₃⁺, which are the most abundant C₂H_x⁺ ions, have additional and more efficient production channels.

The C₂H_x⁺ ions do not react appreciably with molecular hydrogen, CH₄, or N₂, but they give rise to a series of dissociative association reactions with the lesser neutral components of the plasmas (NH₃ and C₂H₂).^{58,59} Other minor ions are also present in this mass range. The peak at $m/q = 28$ is due to N₂⁺ in H₂/N₂ plasmas and C₂H₄⁺ in H₂/CH₄ plasmas;

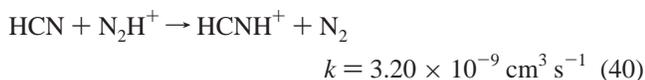
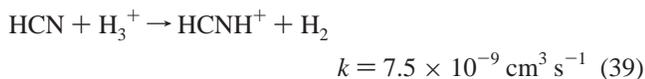
both ions are produced in very similar amounts, and the two signals add up in the H₂/N₂/CH₄ discharges. A signal at mass 29 is also observed in the pure H₂ plasmas. This peak corresponds most probably to HCO⁺ formed in the protonation with H₃⁺ of the CO desorbed from the chamber walls. A minor peak at mass 30, corresponding to ¹⁵NNH⁺, is also observed in the plasmas containing H₂ and N₂. An interesting question concerning the H₂/N₂/CH₄ plasma mixtures is the possible appearance of mixed ions containing carbon and nitrogen. As mentioned above, addition of N₂ to H₂/CH₄ plasmas can inhibit formation of hydrogenated carbon films on metallic walls, which is at present a major issue in the development of next-generation controlled fusion devices.²² Volatile species with C–N bonds like HCN and C₂N₂ have been found in higher pressure (1.5 mbar) MW plasmas containing H₂, N₂, and CH₄ and attributed to gas-phase reactions.^{71,72} Formation of HCN, CN, and C₂N₂ has been reported too in the etching of a-C:H films in nitrogen plasmas.⁷³ Jacob and co-workers stressed the efficiency of chemical sputtering of the carbonated films by N₂⁺ ions^{24,25} and showed that the erosion rate is greatly enhanced through a synergistic effect between ions, penetrating into the film and creating dangling bonds and thermal H atoms, passivating the broken bonds, and giving rise to volatile C_xH_x or C_xN_yH_z stable molecules that would diffuse to the surface and desorb.^{13,24–26} In their CH₄/N₂ plasmas those authors found indeed HCN and C₂H₃ molecules in comparable concentrations.²⁴ In contrast with the CH₄/N₂ plasmas just commented on, those studied here are mainly formed by H₂ with only a small percentage of CH₄ or N₂. Analogous chemical sputtering processes, caused in our case by N₂H⁺ ions, could also take place in the discharges studied in this work, but the desorbed products seem to be somewhat different. In previous studies on similar plasmas Tabarés et al.^{27,29} found that the amount of HCN is very small as compared with that of C₂H_x hydrocarbons. This result has been recently corroborated by new and more refined experiments³⁹ using a newly developed cryo-trapping assisted mass spectrometric technique.⁷⁴ The present ion distribution measurements confirm this conclusion. Electron impact ionization of HCN should lead to formation of HCN⁺, which would also be produced in the very efficient charge-transfer reaction



This ion could, in principle, contribute to the signal at $m/q = 27$, but it is readily transformed to HCNH⁺ in collisions with H₂



Protonation of HCN with H₃⁺ and N₂H⁺ would also lead to production of HCNH⁺

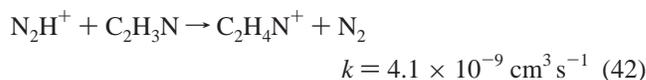
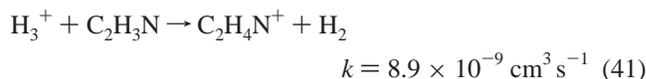


The major species (H₂, N₂, and CH₄) in the discharge do not react with HCNH⁺,⁵¹ and thus, this ion should give a significant contribution to the peak at $m/q = 28$ in mixed H₂/N₂/CH₄ plasmas. Inspection of Figure 4, keeping in mind reactions 37–40, rules out a noticeable presence of HCN in the plasmas

studied: The peak at mass 27, attributed to C₂H₃⁺ in H₂/CH₄ plasmas, does not change with addition of N₂, and the peak at mass 28 in mixed H₂/N₂/CH₄ plasmas corresponds roughly to the sum of the N₂⁺ and C₂H₄⁺ signals in the H₂/N₂ and H₂/CH₄ discharges respectively. No hints about formation of CN or C₂N₂, also typical products of the nitrogen etching, are found in the ion chemistry. The CN radical has been identified via emission spectroscopy, but its concentration must be very small. As for cyanogen, no traces of the primary ion or of its protonated C₂N₂H⁺ derivative were found in the measurements. It seems that in the plasmas dominated by H₂ with only small amounts of nitrogen chemical sputtering or other possible mechanisms of carbon film removal would lead almost exclusively to C_xH_y desorbed species.³⁹ Nevertheless, some evidence for C–N bond formation is discussed below.

Ions of Masses 39–45. Beyond $m/q = 30$ all ions found contain carbon, and most of them are produced in dissociative association processes analogous to those shown in the previous paragraphs. A group of weak signals due to C₃H_x⁺ is found between 39 and 43. The peak at $m/q = 45$, found even in the pure H₂ plasmas, is due to HCO₂⁺ generated in protonation reactions of the traces of CO₂ present as an impurity in the vessel. Although ions in this mass range are produced in very small amounts, their concentration is enriched in the plasma due to the slower flow of heavier ions to the cathode commented on above. The most intense peak in this mass range appears at $m/q = 42$ in plasmas of the H₂/N₂/CH₄ ternary mixture and is mostly due to protonated acetonitrile, C₂H₄N⁺. This is the only C/N mixed ion identified in the plasmas under study. As can be seen, this peak, attributed to C₃H₆⁺ in H₂/CH₄ plasmas, increases by an order of magnitude upon incorporation of N₂. The C₂H₄N⁺ ion is formed probably through protonation of acetonitrile.

C₂H₄N⁺



Protonated acetonitrile does not react with hydrogen^{58,59} and due to its comparatively high mass tends to concentrate in the plasma. In the H₂CH₄/N₂ plasma of this work C₂H₄N⁺ ions make about 1% of the total ion density. Its stability against H₂ makes it a good candidate for observation in the interstellar medium and has in fact been sought, but it has not been unambiguously identified thus far.^{6,75} Production of C₂NH_x species in radical–molecule reactions has been reported previously in RF and MW N₂/CH₄ discharges.^{51,52} Under the conditions of the present experiments, with low gas-phase collision frequency, formation of C₂H₃N is most probably due to surface reactions between carbon- and nitrogen-containing radicals and molecules. In a recent work³⁹ analogous processes involving heterogeneous reactions of carbon radicals with nitrogen-containing molecules at the film surface, leading also to production of C₂NH_x species, have been advanced as a likely way for the effective scavenging of radical growth precursors for formation of a-C:H layers in H₂/N₂/CH₄ plasmas, a mechanism of C-film growth inhibition complementary to that of chemical sputtering mentioned earlier.

5. Summary and Conclusions

The laboratory investigation of cold plasmas in which H₂ is predominant can be of great interest for identification of species

and processes of likely relevance in interstellar space, ionospheres of the giant planets, or controlled fusion devices.

In this work we studied the ion composition of the plasmas formed in low-pressure (0.02 mbar) hollow cathode discharges of H₂ with small admixtures (5%) of CH₄ and N₂. The mass distributions of ions in these plasmas are not dominated by the primary products of electron impact ionization but are rather determined by a rich ion–molecule chemistry dominated by protonation reactions. In all cases the H₃⁺ ion is found to be prevalent, but its concentration is significantly depleted in plasmas containing CH₄ and, most notably, in those containing N₂, where it gives rise to the N₂H⁺ ion. In spite of the small proportion of N₂ in the plasma, this ion can reach concentrations comparable to those of H₃⁺ due partly to its comparatively small flow velocity toward the cathode derived from its larger mass. Both H₃⁺ and N₂H⁺ are very good protonating agents that react efficiently with hydrocarbons. Among the host of ions, other than H_x⁺, found in the plasmas studied, N₂H⁺, CH₅⁺, NH₄⁺, and CH₃⁺ (in that order) have the highest concentrations followed by C₂H₅⁺ and C₂NH₄⁺. Note the prevalence of hydrocarbon ions with odd hydrogen numbers resulting from protonation. All of these major ions are relatively unreactive with H₂ and should thus be relatively stable in the interstellar medium. Two of them, H₃⁺ and N₂H⁺, have in fact been observed, and the present results corroborate that the rest, which are assumed in many astrochemistry models, constitute good candidates for astronomical surveys.

Given the configuration of the discharges studied, with the cathode acting as an effective positive charge sink, all ions observed are formed in the glow region and can give valuable clues about their neutral precursors. The only C/N mixed ion identified in the H₂/CH₄/N₂ mixtures is C₂NH₄⁺, which indicates that acetonitrile, its precursor, is formed in wall reactions between nitrogen- and carbon-containing species. On the other hand, no ions derived from HCN are found in the analysis of the ion distributions, which suggests that hydrogen cyanide is not formed in appreciable amounts.

Although the comparison of the ion distributions of the various discharges investigated in this study provides an approximate global picture of their ion chemistry, further work will be needed for a full understanding of the detailed mechanisms.

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